| Ref # | Hits | Search Query | DBs | Default Operat or | Plural s | Time Stamp |
|----------|------|--|---------------------|-------------------------|-------------|---------------------|
| L2 | Ò | (substrate and first adj lattice and strain adj inducing and second adj lattice and silicon adj germanium and percent). clm. | US-PGPU B; USPAT | OR | ON | 2005/09/20 14:35 |